INCH - POUND

MIL-STD-1772B
22 AUGUST 1990
SUPERSEDING
MIL-STD-1772A
15 MAY 1987

MILITARY STANDARD

CERTIFICATION REQUIREMENTS FOR HYBRID MICROCIRCUIT FACILITIES AND LINES



FSC 5962

FOREWORD

- 1. This military standard is approved for use by all Departments and Agencies of the Department of Defense.
- 2. Beneficial comments (recommendations, additions, deletions) and any pertinent data which may be of use in improving this document should be addressed to: Rome Air Development Center, ATTH: RBE-2, Griffise AFB, NY 13441, by using the self-addressed Standardization Document Improvement Proposal (DD Form 1426) appearing at the end of this document or by letter.
- 3. The purpose of this standard is to establish criteria for certification and qualification as required by MIL-M-38534. Definite criteria will assure that hybrid microcircuits are manufactured under conditions which have been demonstrated to be capable of continuously producing highly reliable products. This is accomplished by evaluating the manufacturer's capability for holding critical processes within established limits at specified critical points and continuously maintaining this capability during production. Certification, qualification and the maintenance is performed in advance of delivery of product and independent of acquisition.

CONTENTS

PARAGI	RAPH																										PAGE
1.		SCO	PE	•		-					•	-	-	-	-	•	-	-	-	-	•	•	-	-	-	•	1
	. 1	P	urp	105	e .	•			•	-	-	-	-	•	-	•	-	-	-	-	-	-	-	-	-	•	1
	. 2					ati					•	•	•	:	•	*	•	•	•	•	•	-	-	-	-	•	1
Τ.	. 3	A	ree	# (o f	con	ic e	rn-	•	•	•	-/	•	•	-	*	-	•	٠	•	•	•	•	•	•	•	1
2		REF	ERE	#C	ED	DOC	UNI	ENT	\$-	-	•	-	-	•	-	-	-	•	•	•	•	•	-	•	•	•	2
_	. 1	Ç	OVE	PN	##N	t d	loci	nme	nt		٠.	•	•	•	•.	•	•	•	•	•	-	-	•	•	•	•	5
	.1.1	\$	Dec	17	içe	tio	ns,		ta	nd	erd	8,	•	nd	•	101	db	00	k s	٠-	-	-	-	•	•	•	2
2.	. 2	0	rde	·F (ĐT	pre	Cet	3 e n	Ce	•	•	•	•	•	•	•	•	•	-	•	•	•	•	•	•	•	2
3.	_	DEF	1 M I	710	D#S	•				•	-	-	-	•	-	•	-	-	-	-	-	•	-	•	•	•	3
3		Ţ	erm		and	de g a	111	nit	10	n.	•	-	•	-	•	*	-	•	•	•	•	•	-	-	-	-	3
_	. 1 . 1	9	uat	111	y 1 n	tio	CT		τy	•	-	•	•	•	•	•	•	•	•	•	-	•	•	•	•	•	3 3 3
	. 1 . 2 . 1 . 3		ert	11	168	tio	י חי		-	-	-		•	•	•		-	-	-	•	•	•		•	•	:	3
																											_
4.		GEN	ERA	ĻI	REQ	UIR	EME	E N T	5 -	,-	-	:	•	- -	•	•	-	-	•	-	-	•	-	•	-	•	- 4
		, C	ert	11	i c s	tio	ار.طا	r.eq	u i.	re	De U	६	_	•	• .	•.7	•	٠.	:	•	•.	•	, - ,	•		•	
	1.1	. <u>P</u>	ocu	-	nta	tio ssu	, w	• •	•				•	• .	•	* -	•	٤.	•	•	•	•	-	-	: .	•	. 4
-	1.2 .	9	na r	1 1	, .		T.	nce	٧	er	111	C 8	יזי	on		•	•	-	•	•	•	•	•	-	•	•	
	1.3	A.		τ .	 	el		•	•	-	-	_	•	•	•	•	•	•	•	•	•	•	-	•	-	•	- 7
7.		D.		1 4	ica	tio		-	u I	-		- -		:			_	-		:	-	_	-		-		- 7
٠.						_		_																			•
5.		DET	AIL	€D	RE	9U 1	REI	4EK	TS	-	-	-	-	•	•	٠	-	-	•	•	•	•	•	-	•	•	5
	. 1		esp	OUI	, [b	111	tí	*	•	-	-	-	-	•	•	•	-	-	-	•	-	•	•	•	-	-	5
	1.1	C.	ert	11	yin	9 •	ct	i v i	ty	•	•	-	-	•	•	•	•	•	•	-	-	•	•	•	-	-	5
	1.2			7.0	ETU	rer			•	•	•		•	-	-	•	•	-	•	-	-	٠,	•	•	-	-	5
	1.3			•		_ :				-		1.						_					_		_	_	5
3.	2.1 2.1.1 2.1.2 2.1.3		-+ h		P. =	". •	<i>n</i>											-	•	-		-	-				5
ζ.	2 1 1		na l	V = 1		of	rei	. w l	t 8		_	Ţ	-				-	_			٠_	_	_		_		5
5.	2.1.2		ort	***	elv		ct	on	•			<u>.</u>	-	-	-			-	-	-	-		-	-	-	-	5
5.	2.1.3	F	req	ue	ncy	of	81	udi	tí	ne	-	-1	-	•	•	•	-	-	•		-	•	•	٠	-	-	5
5.	2.2		∎nu	IT 80	ctu	חוח	10 (con	8 K	DL.	CTI	Qf	1		nr	110	ve		-	-	-	*	-	-	-	•	5
5.	. 3					tío																					
			ech	ņi	dne		nd	88	te	ri	• l #	1	n	e c	C	0	len	C	•	11	h						
_						•																		-	•	•	5
Э.	.3.1		ue i	111	1 40	•	ישחני	rec	tu		ng ala	6 0	me		uc		-	'_	_	_	_	_		_	_	_	6
•	3.2	A .	20 N	-	100	`,'			**		-:-		-	-	-		-	_			_	_	_				6
	3.2.1) C	DF C	7-	: - : v	61	et	100	•	_	_	1	•	•			•	-	•				-		-		6
	3.3	· 5	rea		ncy	of			in		-	_		•	-	•	-	•	•	-	-	-	-	•	•	•	6
			•		-							1															
6.		HOT	ES	•		-	-	-	-	-	•	+	•	-	-	~	-	-	•	-	•	•	-	-	-	•	6
6.		\$	ub j	40	t t		• (I	k e y	•	OF	d)	u	81	in	0	•	-	•	•	-	-	-	•	•	•	•	6
6.	. 2	C	hen	9 6 1	8 7	ros	P	rev	10	uŧ	•0		1 0	חו	-	•	•	•	•	•	•	•	•	•	•	•	6
SECTIO	NS.																										
	_					4									_												7
A		Aud	114	PL	an an	TOF	- TI	BCI	11	71	**	er L	10		n			τ.	T	101) T	101	٦-	•	-	•	•
•		COU		151	, i o	on •	91				-	Ţ	ınc	· •		701			<i>,</i> ,		'_						32
		CON	.	uc i			# 61		44	-	-	Ī	_	_	_		_	-	-	-	-						
TABLES	<u>s</u>																										
	1	\$ ub	2 T F	e e		abr	i e	e t i	on		ا مِن	1.	1 6 4		1	on			_			-		-		-	37
	ż	Sub	str	ate		nd	-1	9 D 4	int		tta	ċł	١ (104	ıŁſ	! f {	e	t l	lot	١.	•	-	~	-	-	•	40
_	- 3	Bon	din	1 B .	in	ter	en.	la	lue	11	fic	ė1	110	מכ	-	-	•	-	-	-	•	-	~	-	-	-	43
į.	- 4	500	Lin	١٠.	de	lid	101	ng '	នព	ıd	res	ė	t I	i ne	1	941	M	1	ica	bt '	10	n-	٠	•	-	-	46
9 -	5A	Qua	LIF	10	ati	on	sul	bgr	ou	P	•	+	•	•	-		-	•	-	•	-	•	•	•	•	-	49
₿.	58	Tes	tin	10	guļ	de l	. In		fo	P	pro	ę٠	81		n	đ											**
			1	- 1						. 44	4 - 4			_	_	_	_	_	_	_	_	-	•	-	-	-	50

1. SCOPE

- 1.1 Purpose. This document establishes minimum requirements governing certification and qualification of manufacturing construction techniques and materials for hybird microcircuits. It is intended to standardize the documentation and testing for hybrid microcircuits for use in military and serospace applications. It covers the interface between user and manufacturer and it is not intended to be a complete set of documentation required to build hybrid microcircuits.
- 1.2 Classification. Hybrid microcircuits covered by this document include all package sizes, class & and class & devices, microwave integrated circuits, switches, relays, oscillators, timers, etc.

1.3 Areas of concern.

- a. All manufacturing construction techniques are documented.
- b. All manufacturing construction techniques are under control.
- c. Conformance to this document and Mil-N-30534.
- d. Supplier control acquisition documents for parts and materials.

2. REFERENCED DOCUMENTS

2.1 Government documents.

2.1.1 <u>Specifications, standards, and handbooks</u>. The following specifications, standards, and handbooks form a part of this document to the extent specified herein. Unless otherwise specified, the issues of these documents are those listed in the issue of the Department of Defense Index of Specifications and Standards (DODISS) and supplement thereto, cited in the solicitation.

SPECIFICATION

MILITARY

MIL-H-38534 - Hybrid Microcircuits, General Specification for.

STANDARDS

. WILITARY

MIL-STD-750 - Test Methods for Semiconductor Devices.

MIL-STD-883 - Test Methods and Procedures for Microelectronics.

'(Unless otherwise indicated, copies of federal and military specifications, standards, and handbooks are available from the Standardization Documents Order Desk, Building 4D, 700 Robbins Avenue, Philadelphia, PA 19111-5094.)

2.2 Order of precedence. In the event of a conflict between the text of this document and the references cited herein, the text of this document takes precedence. Nothing in this document, however, supersedes applicable laws and regulations unless a specific exemption has been obtained.

3. DEFINITIONS

- 3.1 Terms and definitions. The following terms and definitions shall be as specified in MIL-M-38534, MIL-STD-883, and herein.
- 3.1.1 <u>Qualifying activity</u>. The organizational element of the Government that grants certification and qualification for the manufacturing construction techniques and materials in accordance with this specification and the applicable detail specification.
- 3.1.2 <u>Certification</u>. The process by which a manufacturer's facilities are audited and approved for compliance with the requirements of section A of this document and MIL-M-38534.
- 3.1.3 <u>Qualification</u>. The process by which a manufacturer's manufacturing construction techniques and materials are tested and approved for compliance with the requirements of section B of this document.

4. GENERAL REQUIREMENTS

- 4.1 <u>Certification requirements</u>. The following requirements are applicable for the general line certification.
- 4.1.1 <u>Documentation</u>. The manufacturer shall have available for on-site review by the certifying activity documentation that demonstrates process control and test capability as defined in MIL-R-38534.
- 4.1.2 Quality assurance varification. Quality assurance varification shall be in accordance with appendix A of M1L-8-38534.
- 4.1.3 <u>Audit</u>. The certifying activity reserves the right to audit the facility in accordance with section A of this document and MIL-M-38534. The audit plan of section A herein shall be used for keeping the line certification current.
- 4.1.4 <u>Audit level</u>. The qualification activity will conduct a class K audit of a facility only if the facility has class H certification.
- 4.2 <u>Qualification requirements</u>. The requirements of section B herein are applicable for qualifying and maintaining manufacturing construction techniques and materials used in the production of hybrid microcircuits.

5. DETAILED REQUIREMENTS

5.1 Responsibilities.

- 5.1.1 <u>Certifying activity</u>. The certifying and qualifying activity shall be responsible for the following:
 - a. Scheduling and conducting the audit in accordance with section A of this document and NIL-N-38534.
 - b. Reporting the audit results as specified in 5.2.1.1.
 - c. Maintaining audit results for review by acquiring activities.
 - d. Approving section & testing.
 - e. Preparing and maintaining a qualified manufacturers list (QRL).
- 5.1.2 <u>Manufacturer</u>. The manufacturer shall notify the certifying activity of any major change, as defined in MIL-R-38534, in a certified facility. The certifying activity may choose to:
 - a. Approve the change without further testing.
 - b. Require specific testing.
 - c. Require complete recertification.
- 5.1.3 Acquiring activity. The acquiring activity shall review audit results (maintained by the certifying activity) to verify that the manufacturing construction techniques and materials used at the time of the audit adequately represent those to be used in the impending procurement.
- 5.2 Audit plan in accordance with section A. The purpose of the audit plan is to provide a systematic method for determining a manufacturer's conformance to the product assurance requirements of MIL-M-38534 and MIL-STD-883. The plan contains audit requirements that serve as the basis for initial and continuing certification for manufacturers of custom hybrid microcircuits.
 - 5.2.1 Method. This procedure details the following:
- 5.2.1.1 Analysis of results. The representative of the certifying activity shall provide an exit debriefing immediately following the audit, and a summary report within 30 days to the manufacturer's quality management. The written summary report shall include specific details of any condition less than full compliance.
- 5.2.1.2 <u>Corrective action</u>. Corrective action or justification is required whenever any condition less than full compliance exists. The certifying activity shall review and approve the corrective action.
- 5.2.1.3 Frequency of auditing. Audits in accordance with section A of this document shall be performed once every two years.
- 5.2.2 <u>Manufacturing construction techniques</u>. This document is not intended to direct or select the use of any particular manufacturing construction techniques but only to standardize on the minimum muditing required to assure that the manufacturing construction techniques will continue to generate satisfactory products.
- 5.3 Qualification of manufacturing construction techniques and materials in accordance with action B. The purpose of this section is to document a systematic and uniform method of qualifying various manufacturers' construction techniques. This section provides the methods to establish a baseline and evaluate proposed changes in construction techniques, materials, or design to assure that such changes will maintain or enhance instead of degrading the quality or reliability of the hybrid.

- 5.3.1 <u>Qualified manufacturing construction techniques and materials</u>. This section is not intended to direct or select the use of any particular construction or handling process, but provides a minimum standardized method of qualification to assure that the manufacturing construction techniques will generate hybrids that will satisfy the requirements of MIL-H-38534.
- 5.3.2 <u>Analysis of results</u>. The detailed results of section B testing must be submitted for review by the qualifying activity.
- 5.3.2.1 <u>Corrective action</u>. Corrective action or justification is required whenever any condition less than full compliance exists and shell be approved by the qualifying activity.
- 5.3.3 <u>Frequency of testing</u>. Testing in accordance with section B of this document shall be performed for initial certification and shall be updated when new manufacturing construction techniques and materials to be covered by certification and qualification are introduced.

6. MOTES

(This section contains information of a general or explanatory nature that may be helpful, but is not mandatory.)

6.1 Subject term (key word) listing.

Audit Hybrid microcircuit Requirements, certification Requirements, qualification.

6.2 Changes from previous issue. Marginal notations are not used in this revision to identify changes with respect to the previous issue due to the extensiveness of the changes.

#IL-STD-17728

SECTION A

AUDIT PLAN FOR FACILITIES AND LINE CERTIFICATION

TABLE OF CONTENTS

AUDIT SECTION Number	TITLE
A-1	Quality assurance program
A-2	pesign guidelines and documentation
A-3	Quality conformance evaluation
A-4	Vorkmansh i p
A-5	Cleanliness and atmospheric control
A-6	incoming material control
A+7	Substrate fabrication
A-8	Polymeric materials
A-9	Substrate and circuit element attachment
A-10	Internal visual
A-11	Wire bond
A-12	Cleaning
A-13	Package seat
A-14	Screening
A-15	Acceptance for shipment
A-16	Randling and storage
A-17	failure analysis
A-18	Training
A-19	Certification/qualification program

AUDIT SECTION MUMBER A-1

QUALITY ASSURANCE PROGRAM

Requirement:	The manufacturer shall have established, immediately assurance program in MIL-M-38534.	plemented accordanc	, and a	hall be
Reference:	Appendix A of MIL-H-38534.			
DETAILS:	verify conformance to the following as appl	icable:		
s. Manufac	turer documentation:	<u>APPROVAL</u>		COMMENTS
	nversion of customer requirements into nufacturer's internal instructions.	••,	· .	
) Travelers(s) or a mandatory detailed check- list demonstrating full compliance to test method 5008 of NIL-STD-883. This includes requirements for incoming inspection (eleme evaluation), process control, screening, an quality conformance evaluation.		· · ·	
(b	 Review of SCD for specification of test conditions, electrical parameters (at temperature), and to compliance of appendix of NIL-N-38534. 	· c	 	
(c) Materials and processes as listed on the QM	ı		
(d) Design requirements of MIL-H-38534.			
(•) Marking requirements of MIL-8-38534.			
(1	 Documents utilized are on approved baseling listing. 	·	_	
< 6) Travelers in accordance with section C(10).			·
()) Test methods per laboratory suitability letter or DESC approved laboratory.			
(1) Rework attemed per MIL-W-38534.			
(2)	Puality control operations.			
(3)	Quality assurance operations.			
	rool and test equipment maintenance and calibration.			
(5)	Corrective action and evaluation.			
(6)	Schematics, testing, burn-in.			
b: Menuf	acturer records:			
(1)	Equipment calibrations.			

1/ Not applicable.

(2) Product lot identification.

M1L-STD-17728

		QUALITY ASSUR	ANCE PROGRAM	APPROVAL	N/A COMMENTS
с.	Manu	facturer program plan:			
	(1)	Functional block organizational	chart.		
	(2)	Manufacturing flow chart: Gene chart(s) detailing receipt of m through shipment of completed h	aterial		
	(3)	Proprietary-document listing.			
	(4)	Examples of design, material, e and processing instructions.	quipment,		
	(5)	Examples of records.		· · ·	
, .	(6)-	Examples of design, material an change control documents:	d process		: :
		(a) A change control system.	,	•••	· · · ·
		(b) The change control syste implemented and enforced			
	(7)	Examples of failure and defect and feedback documents.	enatysis		
	(8)	Examples of corrective action a evaluation documents.	nd		
	(9)	Manufacturer's internal instruction internal visual inspection.	tions for		
į	(10)	Examples of test travelers.			
		ncoming evaluation, acreening, a nd QCI travelers shall include t s a minimum:			
		(a) Identification as to wheth is qualification or QCI.	er the lot		
		(b) Heme and title of operation specification number and reach process or test.			
		(c) Identify part number, date manufacturer internal lot number(s).			
		(d) Date(s) of test or process operator identification.	end		
		(e) Calibration control number identification of all major components used for test.			
		(f) Quantity tested and reject process or test. (Actual of tested, if sampled.)			
		(g) Serial numbers of passing	and failing		

QUALITY ASSURANCE PROGRAM

APPROVAL

N/A COMMENTS

(h) Time in and out of process or test if critical to process or test results (i.e., burn-in and 96 hour window).	
 The percent defective calculated for burn-in. 	
(j) Burn-in life test board serial number or test circuit identification number and revision.	
(k) Identification and disposition of any parts removed from the lot.	<u> </u>
Note: Alternate means of meeting these requirements may be approved by the qualifying activity. Only items b, c, d, f, h, and k shall apply to fabrication and assembly travelers.	
(11) Examples of design and construction baseline.	
(12) Ranufacturer's self audit.	·
Company audited:	·
Performed by:	
Date:	•
Comments:	

AUDIT SECTION NUMBER A-2

DESIGN GUIDELINES AND DOCUMENTATION

Requirement:	The menufacturer shall esta microcircuits and a baselin accordance with MIL-N-38534	e of documents for	for the design of or each design in
Reference:	MIL-M-38534,		
DETAILS:	Verify that the manufacture	r has:	
			CONNENTS
	materials: Substrate condurs, adhesives, and coatings.	ctorm, .	
b. Package lead mat	materials: External element erial, and plating finish.	s, metals,	
c. Package	construction including seal.		
d. Internal	conductors: Current-power	capability.	
	internal elements: Plating s, and thickness.	, attach,	
f. Thermal	design: Including dereting.		·
g. Electric	al design: Stress, temperat	ure, etc.	·
h. Document	ation: Baseline per device	type.	· · · · · · · · · · · · · · · · · · ·
(1) T <i>o</i> p	ography, bonding diagram.	•	
(2) \$ch	ematic and logic diagrams.		
rev	ufacturer utilizes the appli- ision documents pertaining t roved baseline.		
Company audite	d:		•
Performed by:			
Date:			_ ··· _
Comments:			
		-	

AUDIT SECTION NUMBER A-3

QUALITY CONFORMANCE EVALUATION

	irement:	The manufacturer's quality conformance pro- accordance with MIL-N-38534 and herein.		•		
Refe	rence:	M1L-N-38534.				
DETA	ils:	Verify conformance to the following as app	licable:			
			APPROVAL	K/A	CONNE	<u>(15</u>
••	Group A MIL-H-3	on each inspection lot in accordance with 8534.				
b .		on each inspection lot in accordance with 8534.		<u>. </u>	· ·	•
· c.	A syste	inspection in accordance with MIL+N-38534, m to insure group C performed on first lot ed is needed.				· :
d.		inspection in accordance with MIL-H-38534. The to track group D coverage is needed.				
e.	inspect from th	ion and control of inspection tot(a). ion lot identification shall be maintained a time of lot assembly through acceptance lot. Date code system.			,	
1.	Must de	fine add-on and resubmittal procedures.				
g.		lure disposition and notification of er and/or certifying activity.				
		•				
Comp	any audit	●d:				
Perf	ormed by:		·			
Date	:					
Com	ents:					

MIL-STO-17728

AUDIT SECTION NUMBER A-4

MORKMANSHIP

• qu i	rement	: The manufacturer's documents shall be in an Mil-H-38534.	ccordance w	ith
efer	ence:	M1L-M-38534.		
<u>etai</u>	<u>LS:</u>	Verify existence of the procedures and con- applicable:	formance to	the process as
			APPROVAL	N/A COMMENTS
a .	Rewor	k/repair:		
	(1)	Temperature controls.		<u> </u>
	(2) !	Puckage rework limitations.		
•	(3)	Provision for complete rescreening.	·	
	(4)	: Element replacement limitations.		•
		Time/temperature limits specified and documented.		<u> </u>
ь.	Wire	rebonding:		
	(1)	Limitations documented for circuit elements.	·	
	(2)	Limitation documented for substrate.		·
c .	Delid	and reseal:		
	(1)	Process documented and qualified.		
	(2)	Process sheets at work station.		
	(3)	Neets delid limitation.		
d.	Other	•		
ompa	ny aud	Ited:		
erfo	rmed b	y: •		
ate:				
0 200	nts:			

AUDIT SECTION NUMBER A-5

	CLEANLINESS AND ATMOSPHERIC CONTR	OL	•
Requirement:	Cleanliness and atmospheric control shall requirements for each area in which unseal parts are stored, processed, or assembled.	ed units ar	ented nd component
Reference:	Appendix A of MiL-H-38534, cleenliness and areas.	atmosphere	control in wor
DETAILS:	Verify conformance to the following, as ap	plicable:	
		APPROVAL	N/A COMMENTS
a. Specifi	ed facility cleaning.		
b. Particļ	e count.	<u>·</u>	<u> </u>
.c. Tempere	ture and humidity.		<u> </u>
d. General	housekeeping.		
e. Documen	tation.		
f. Human c	ontamination.	*** <u>**********************************</u>	
			٠
		•	
_			
Company audit	ed:		
Performed by:			
Date:		_	
Comments:			

HIL-STD-17728

AUDIT SECTION NUMBER A-6

INCOMING MATERIAL CONTROL

Inspection operations shall be documented as to type of inspection, Requirement: sampling and test procedures, acceptance-rejection criteria, and frequency of use. Method 5008 of MIL-STD-883, test procedures. MIL-W-38534, inspection of incoming materials. References: DETAILS: Verify conformance to the following, as applicable: APPROVAL N/A COMMENTS Chip components: thip topology conforms to that specified on . manufacturer's acquisition document. Incoming visual inspection. c. Incoming electrical testing. d. Storage in controlled environment. Electrical test verification. Use of electrical test program or correlation units to verify electrical test setup within applicable device specification limits. Correlation units may be generic types that include tested parameter ranges for a group or family of devices. Test equipment calibration. Case, package, and cover (lid): Case and cover type conforms to type specified on menufacturer's acquisition document. Compliance with tables V and VI, method 5008 of MIL-STD-883. c. Plating thickness. Other: Incoming parts and materials are inspected. Documented procedure for incoming inspection to include sampling procedures lot accept and reject criteria and frequency of testing. Documented procedure for handling discrepant parts and materials. Rework.

Verification of element evaluation performed at the element supplier in lieu of incoming

inspection.

MIL-STD-1772B

AUDIT SECTION <u>NUMBER</u> A-6	INCOMING MATERIAL CONTROL	
COMPANY AUDITED:	·	
PERFORMED BY:		_
DATE:		
COMMENTS:		

AUDIT SECTION NUMBER

SUBSTRATE FABRICATION

Each step of substrate fabrication shall have documented Requirement: Method 2017 of MIL-STD-883. verify conformance to the following, as applicable: DETAILS: M/A COMMENTS APPROVAL a. Cleaning procedures. b. Printing (thick film). c. Drying (thick film). ... d. firing (thick film). e. Deposition (thin film). f. Plating (thin film). g. Etching (thin film). h. Photolithography (thin film). i. Resistor trimming. Documentation. k. Rework. Inspection. Substrate separation technique. n. Testing. Company sudited: Performed by:

AUDIT SECTION NUMBER A-8

POLYMERIC MATERIALS

Requirement:	All polymeric materials have their own un handling, storage, and application/usage	nique require	ments for
References:	Method 5011 of MIL-STD-883 MIL-M-38534.		
DETAILS:	Verify conformance to the following, as	epplicable:	
		APPROVAL	M/A COMMENTS
e. Meteria	is tested to method 5011 of MIL-STD-883.		
b. Storage			
	ife identified and followed.	· · · · · · · · · · · · · · · · · · ·	
e. Cure co	nditions specified and followed.		
			·
Company audit	ed:		
Performed by:			•
Date:			
Comments:			

AUDIT SECTION MUMBER A-9

	SUBSTRATE AND CIRCUIT ELEMENT ATTA	CHMEN	ľ			
Requirement:	The documentation and performance of the circuit elements are incorporated into the microcircuit shall be evaluated.	proce he ass	ss ste embly	ps by of a h	which ybrid	
References:	Methods 2017 and 5008 of MIL-STD-883. MIL-H-38534.					
DETAILS:	Verify conformance to the following, as		able:	N/A	COMME	<u>nts</u>
Substrate and	circuit elements are attached:	·				
a. In acco	rdance with layout.					
•	rdance with method 2017.	-	<u> </u>		•	<u>. </u>
c. Rework.		_	:		:	
Process contro			:		•	
	ance to documentation.	_				
	ble revision.		•			
-	ives for ettachment:					
	ife control.				_	_
of time	conforms to documentation in terms, temperature, and effectiveness.	_				
Metallic mete	rial attachment:					
s. Materia	l is in accordance with documentation.	_				
b. Process time, t	conforms to documentation in terms of emperature, and effectiveness.				• • •	
Company audit	ed:					
Performed by:						
Date:						
Comments:						

AUDIT SECTION NUMBER A-10

INTERNAL VISUAL

Requirement:	Internal visual inspection procedures shal conformance to method 2017.	t be evalu	eted f	or
References:	Methods 2017 and 2010 of MIL-STD-883, and MIL-H-38534.	method 207	5 of M	1L-STD-750
DETAILS:	Verify conformance to the following, as as	plicable:		
		APPROVAL	M/A	COMMENTS
a. Methods	2010, 2017, 2072, and 2073.			
bProper i	inspection equipment.			·
c- Workbens d. Visual i	hip standards.	•	·- <u>:</u>	
e. Rejectio	ons are documented.		·	
f. Provisio	ons of reinspecting rework.			
	nation control documentation during g, transportation, and storage.			
h. Damage p	prevention documentation.	•		
Confirm:				
a. Monitori	rework history.			
b. Initiate	es corrective action.			•
c. Monitor	corrective action.		_	
Company audito	od:			
Performed by:				
Date:				
Comments:				
	•			

AUDIT SECTION NUMBER A-11

WIRE BOND

									•									
Requirement: Wire bonding documentation ascertain adequate process		n and	i ope itrol	rati	ons	shal	l be	24	ai ua t	ed t	D							
Refer	ences	:			de 201 38534		023,	and St	008	of MI	L-ST	D - 88	3.					
DETAI	LS:		٧	erify	y conf	forms	nce t	o the	fol	louin	9, .	. •p	plic	. oble	:			
													APP	ROYA	<u>L</u>	K/A	CON	MENTS
٠.	For	each	ı bo	ondi:	ng sti	tion	:									•	•	
	(1)							icate ments		forma	nce		_			_	<u> </u>	
•	(2)	Eva	lui h	etio neth	n and	prbc 08.	ess c	bntro	i		rdan	ce		•	. ·		· · ·	·· ·
•	(3)	Con	1110	ol s	ettin	er ag	nge:				:							
		(+)) 1	T i me									_	·				
		(b)) 1	Temp	eratui	ře.							_	_				
		(c)) (Pres	sure.								_			_		
		(d)) (Powe	r.								_					
	(4)	Doc	c um	enta	tion	for p		s ope	reti	on.			<u>.</u>					
	(5)	Vis	8 U B	l ai	ds.								_					
	(6)	Res	MOL	k.									_				_	
	(7)	Equ	u i p	ment	main	tenar	ice.						_			_		
ь.	For	the	рu	il t	est •	qui pe	ent:											
	(1)	Cel	Lib	rati	on pr	ocedu	ıre.						_					
	(2)	Fre	equ	ency	of c	a L i br	ration	١.					_					
ε.	Corr	ecti	ive	act	ion:													
	(1)	l eş	ple	ment	et ion	of c	.0770	tive	acti	on.			_	_				
	(2)	Cor	ntr	ol a	1 cor	recti	ive s	ction.	. .									
Comp	eny et	ıdi te	ed:	·														
Perf	ormed	by:				_									_			
Date	:	-																
	ents:			_													_	
																		

AUDIT SECTION MUMBER A-12

CLEANING

a. Documentation: (1) Exposure times and techniques. (2) Storage environment. b. Mechanical. c. Gas blow off. d. Vapor degreaser: (1) Solids contamination control. (2) Liquid contamination control (acidity). e. Liquid wash: (1) Solids contamination control. (2) Liquid contamination control. (2) Liquid contamination control. (3) Liquid contamination control (acidity). f. Plasmas. g. High temperature vacuum bake.	quirements for a start of the s
a. Documentation: (1) Exposure times and techniques. (2) Storage environment. b. Mechanical. c. Gas blow off. d. Vapor degreaser: (1) Solids contamination control. (2) Liquid contamination control (acidity). e. Liquid wash: (1) Solids contamination control. (2) Liquid contamination control (acidity). f. Plasmas. g. High temperature vacuum bake.	
a. Documentation: (1) Exposure times and techniques. (2) Storage environment. b. Mechanical. c. Gas blow off. d. Vapor degreaser: (1) Solids contamination control. (2) Liquid contamination control (acidity). e. Liquid wash: (1) Solids contamination control. (2) Liquid contamination control. (2) Liquid contamination control. (3) Liquid contamination control (acidity). f. Plasmas. g. High temperature vacuum bake.	
(1) Exposure times and techniques. (2) Storage environment. b. Mechanical. c. Gas blow off. d. Vapor degresser: (1) Solids contamination control. (2) Liquid contamination control (acidity). e. Liquid wash: (1) Solids contamination control. (2) Liquid contamination control. (2) Liquid contamination control (acidity). f. Plasmas. g. Righ temperature vacuum bake.	COMMENTS
(2) Storage environment. b. Mechanical. c. Gas blow off. d. Vapor degreaser: (1) Solids contamination control. (2) Liquid contamination control (acidity). e. Liquid wash: (1) Solids contamination control. (2) Liquid contamination control (acidity). f. Plasmas. g. Righ temperature vacuum bake.	
b. Mechanical. c. Gas blow off. d. Vapor degreaser: (1) Solids contamination control. (2) Liquid contamination control (acidity). e. Liquid wash: (1) Solids contamination control. (2) Liquid contamination control (acidity). f. Plasmas. g. Righ temperature vacuum bake.	· · · · ·
c. Gas blow off. d. Vapor degreaser: (1) Solids contamination control. (2) Liquid contamination control (acidity). e. Liquid wash: (1) Solids contamination control. (2) Liquid contamination control (acidity). f. Plasmas. g. Righ temperature vacuum bake.	.
d. Vapor degreaser: (1) Solids contamination control. (2) Liquid contamination control (acidity). e. Liquid wash: (1) Solids contamination control. (2) Liquid contamination control (acidity). f. Pleases. g. Righ temperature vacuum bake.	
(1) Solids contamination control. (2) Liquid contamination control (acidity). e. Liquid wash: (1) Solids contamination control. (2) Liquid contamination control (acidity). f. Pleames. g. Righ temperature vacuum bake.	· · · · · · · · · · · · · · · · · · ·
(2) Liquid contamination control (acidity). e. Liquid wash: (1) Solids contamination control. (2) Liquid contamination control (acidity). f. Plasmas. g. Righ temperature vacuum bake.	
e. Liquid wash: (1) Solids contamination control. (2) Liquid contamination control (acidity). f. Pleases. g. Righ temperature vacuum bake.	
(2) Liquid contamination control (acidity). 1. Plasmas. g. Righ temperature vacuum bake.	
f. Plesmes. g. High temperature vacuum bake.	
g. Righ temperature vacuum bake.	
h. Inspection/test.	
i. All cleans prior to final visual.	
]. Precautions for wire bonds.	
Company audited:	
Performed by:	
Date:	
Comments:	

AUDIT SECTION NUMBER A-13

PACKAGE SEAL

a. Present bake cycle: (1) Time. (2) Jemperature. (3) Atmosphere. b. Sealing: (1) Process documentation in work area. (2) Sealing schedules are recorded and maintained. (3) Monitor moisture.			COMMENTS
a. Present bake cycle: (1) Time. (2) Jamperature. (3) Atmosphere. b. Sealing: (1) Process documentation in work area. (2) Sealing schedules are recorded and maintained. (3) Monitor moisture.		E/A	
a. Present bake cycle: (1) Time. (2) Jemperature. (3) Atmosphere. b. Sealing: (1) Process documentation in work area. (2) Sealing schedules are recorded and maintained. (3) Monitor moisture.	ROVAL	: :	COMMENTS
(1) Time. (2) Jemperature. (3) Atmosphere. b. Sealing: (1) Process documentation in work area. (2) Sealing schedules are recorded and maintained. (3) Monitor moisture.			
(3) Atmosphere. b. Sealing: (1) Process documentation in work erea. (2) Sealing schedules are recorded and maintained. (3) Monitor moisture.			
(3) Atmosphere. b. Sealing: (1) Process documentation in work area. (2) Sealing schedules are recorded and maintained. (3) Monitor moisture.			
b. Sealing: (1) Process documentation in work area. (2) Sealing schedules are recorded and maintained. (3) Monitor moisture.		·	
(1) Process documentation in work area. (2) Sealing schedules are recorded and maintained. (3) Monitor moisture.		· 	
(2) Sealing schedules are recorded and maintained			
(3) Monitor moisture.			
•			
Add Barrack			
(4) Rework.			
c. Conformance to method 1014:			
(1) Fine Leek.	·		
(2) Gross teak.			_
Company audited:		•	
Performed by:		•	
Date:			
Comments:			

AUDIT SECTION NUMBER A-14

SCREENING

Requi	rement:	Screening documentation and operations she ascertain adequate process control.	ili be evalu	jet ed	to
Refer	rence;	MIL-STD-883.			
DETAI	LS:	Verify conformance to the following, as ap	plicable:		
			APPROVAL	M/A	COMMENTS
	Preseal	burn-in, method 1030:			
	(1) En	vironmental control.			<u>·</u>
٠.	(2) De	vice protection.			
	(3) Pr	oper burn in circuit.	·		
•	(4) Pr	oper voltages and signals.		<u>.</u>	<u> </u>
	(5) Te	mperature control.			
	(6) Pr	eburn-in log.			
b.		ructive bond pull, method 2023, my of calibration.			
c.	Interna	l visual, precap, method 2017.		_	<u></u>
d.	Stabili	zation bake, method 1008.			
e.	Tempera	ture cycling, method 1010.			
f.		t acceleration, method 2001 or cal shock, method 2002.			
8-	Perticl	e impact noise detection (PIND), method 2020):		
	(1) Sy	etem calibration.	· ·		
	(5) No	unting methods.			
h.	Proburn	-in electrical test:			
	(1) Te	at procedure, applicable revision.			
	(S) Ce	librated electrical instruments.			
	(3) ce	librated temperature probes.			
		rification of test procedure by means testing a correlation unit.	_		
	(5) Da	ta recording.			
í.	Burn-in	, method 1015:			
	(1) Pr	oper burn-in circuit.			

(2) Proper voltages and signals.

AUDIT SECTION NUMBER A-14

SCREENING

			APPROINE	HAY PANNERIS
	(3) Temperature control.			
	(4) Burn-in log.			
	(5) Control of burn-in board and a	ocket testing.		
j.	Electrical test:			
	(1) Test procedure, applicable rev	ision.		
	(2) Calibrated electrical instrume	nts.		
	(3) Calibrated temperature probes.		<u>-</u>	<u> </u>
. :	(4) Verification of test procedure of testing a correlation unit.	by means	· · · · · · · · · · · · · · · · · · ·	
	(5) Data recording.			,
k.	Seal, method 1014:			
	(1) Fine.			
	(2) Gross.			
ι.	Rediographic, method 2012.			
■,	External visual, method 2009.		<u>·</u>	
		·	•	
Compa	ony audited:			
Perf	preed by:		•	
Date:		<u> </u>		
Comme	onts:			
		<u> </u>		· - · · · · · <u>-</u>

AUDIT SECTION NUMBER A-15

ACCEPTANCE FOR SHIPMENT

Requirement:	The traveler record shall be evaluated for units shall be examined for external pack	or completen cage require	ess, and the ments.
References:	Method 2009 of MIL-STD-883. MIL-M-38534.		
DETAILS:	Verify conformance to the following, as a	pplicable:	
		APPROVAL	H/A COMMENTS
Review record	for the following:		
a, Maximum	allowed rework.		
	tion of rework.	· .,	
d. PDA rev			•
	ation of QCI coverage.		
f. Verific	ation of GML coverage.		
Verify confor	mance to method 2009 and SCD requirements.		
Review microc	ircuit marking:		
a. Legibil	ity.		<u> </u>
b. "Seriali	zation.		
c. Resists	nce to solvents, method 2015.		· ·
Verify specie	i customer requirements.		
Company sudit	od:		
Performed by:			<u>.</u>
Date:	· · · · · · · · · · · · · · · · · · ·	<u> </u>	•
Comments:			

MIL-STD-1772B

AUDIT SECTION NUMBER A-16

. , ,	NAMDLING A	AND STORAGE		
Requirement:	The handling and storage o the completed and sealed h		m component	parts through
References:	Method 5008 of MIL-STD-883 MIL-N-38534,			
DETAILS:	Verify conformance to the	following, as a	pplicable:	
	•		APPROYAL	N/A COMMENTS
	ation utilized to identify and storage requirements.	 critical 	<u>———</u> -	
b. ESD pres	tices defined and followed.		· <u></u>	
c. Packagin	g/protection:			
d. Enviróns	ental/atmospheric.			
•	•			
		1		
Company audite	rd:			
Performed by:				
Date:				•
Comments:				

AUDIT SECTION NUMBER A-17

FAILURE ANALYSIS

Requirement:	To have the capability of ena corrective action can be effe	lyzing proble	ms on hybri	ids so that
References:	method 5003 of Mil-STD-883 Mil-H-38534.			
DETAILS:	Verify conformance to the fol	lowing, as ap	plicable:	
			APPROVAL	H/A COMMENTS
a. Manufac enalysi	turer has minimum capability to a to test condition A of method	perform 1 5003.	·	· · · · · · · · · · · · · · · · · · ·
b. Documen	tation of results.		• .	
c. Defe fe	edback/corrective action.			
d. Handlin	g of customer returns.	•	· · ·	
		,		:
Company audit	ed:	 		
Performed by:				
Date:				
Comments:				

AUDIT SECTION NUMBER A-18

TRAINING

Requirement:	The training program and d document.	ocumentation sha	il meet the	referenced
Reference:	MIL-M-38534.			
DETAILS:	Verify conformance to trei processes, as applicable:	ning in the crit	ical hybrid	manufacturing
			APPROYAL	H/A COMMENTS
s. Cleaning		·		
b. Element	ettachment.	·		
c. Substrate	e attachment.		. <u> </u>	
d. Bonding.			·	
e. Sealing.			·	
f. Rework/r	epair.	}		
g. ESD prac	tices.			
h. Inspecti	on.			
i. Clean ro	om practices.		 	<u> </u>
j. Substrat	e fabrication.			
Company audite	d:			
Performed by:				
Dete:				
Comments:				

AUDIT SECTION NUMBER A-19

CERTIFICATION/QUALIFICATION PROGRAM

The test methods shall meet the referenced documents. Requirement:

Reference:

MIL-STD-883.

DETAILS:

Verify conformance of specified documents to applicable test methods

of MIL-STD-883.

lest method	Mumber	Condition Comments
Stabilization bake	1008	C, F
Temperature cycle	1010	B,C (50 cycles max)
Thermal shock	1011	c : .
internal visual	2017	•
Internal visual	2010	A*,B
Internal visual	.2072 1/	
	2073 <u>1</u> /:	
Physical dimensions	2016	
Solderability	2003	
Bond strength	2011	Per bond type
Lead integrity	2004	B1, B2, D Alor B, and £ or D and A,
Seal	1014	A'or B, and E or D and A ₄
Noisture resistance	1004	4084044444
Steady state life	1005	125°C/1000 hours
Salt atmoshpere	1009	
Pre-seel burn-in	1030 2/	
External visual	2009	•
Resistance to solvents	2015	
Internal visual mechanical	2014 1018	
Internal water vapor Vibration	2007	
VIDENTION ESD	3015 ·	A-1
Dye penetrant	1772	(4.3.2) 2/
Loose particle detection	1772	(4.3.1)
Insulation resistance	1003	600 V dc. 100 nA
Mon-destruct bond pull	2023	000 4 GC, 100 Hz
Mechanical shock	2002	C B (Y. axia)
Constant acceleration	2001	C, B, (Yq exis) A, B, C, D (Yq exis)
PIND	2020	A* or B
Burn-in	1015	
Rediction Latch*	1020	
Steady state total dose*	1019*	
Neutron irradiation*	1017*	
Die eheer	2019	
Rediography	2012 3/	Y axis
failure enalysis	5003	A, 8°
Forward voltage	3071 1/	•
Seturation V-E	4011 1/	
Voltage conditioning on aging*	5008	Table IV
SEM	2018*	
Polymeric meterial	5011	•

Required for class 5. MIL-STD-750 methods

^{1/} MIL-STD-750 methods 2/ Optional, 3/ Metallic attach only.

AUDIT SECTION NUMBER A-19

CERTIFICATION/QUALIFICATION PROGRAM

Test method	N umbe:	Condition	Document number/ <u>comments</u>
Electrical (1) General requi	rements	A1, A2, A3, ar A4, or A7	nd
(2) Passive elemen	nts 5008	(3.2.3.5)	
(3) MIL-S-19500 Adhesion Conductivity resisting (four point probe)	1772 vity 1772	A2, A3, and A4 B	L
Company audited:			 .
Performed by: <u> </u>		: · · · · · · · · · · · · · · · · · · ·	
Date:		·	<u> </u>
Comments:			· · · · · · · · · · · · · · · · · · ·

SECTION B

QUALIFICATION OF MATERIALS AND MANUFACTURING CONSTRUCTION TECHNIQUES

TABLE OF CONTENTS

LILLE

Subsection B-1	Thick and thin film fabrication
Subsection B-2	Substrate and element attachment
Subsection 8-3	Bonding, internal
Subsection B-4	Sealing, delidding, and resealing
Subsection 8-5	Qualification option
Tables 8-1 through 8-5	Qualification testing tables

1. SCOPE .

- 1.1 <u>Purpose</u>. This section establishes general requirements applicable to initial qualification testing and qualification of additions and changes to materials and manufacturing construction techniques for both classes K and H quality levels. Qualification shall be performed to subsections B-1, B-2, B-3 and B-4 if special test vehicles are to be used for qualification; or, at the manufacturers' option, to subsection B-5 if actual functioning hybrid microcircuit devices or special test vehicles are used for qualification.
- 1.2 <u>Frequency of testing</u>. The manufacturer is eligible to begin qualification testing after certification is granted. However, qualification shall be achieved no later than aix months after certification. After completion and approval of initial qualification testing, the applicable subsection of MIL-STD-1772, section 8 testing shall be repeated annually for those materials and manufacturing construction techniques which, during the certification year, were not subjected to quality conformance evaluation of MIL-M-38534. Repeating section 8 qualification testing annually shall not be acceptable in lieu of quality conformance inspection. Certain subsections of MIL-STD-1772, section 8, may be required, as determined by the qualifying activity, to be repeated for changes or additions to materials and manufacturing construction techniques.
 - 1.3 Areas of concern. (See subsections.)
 - 2. GENERAL REQUIREMENTS
- 2.1 <u>General qualification requirements</u>. The general inspection conditions of MIL-N-38534 apply. The tests, test methods, test conditions, and testing limits shall be in accordance with MIL-N-38534, MIL-STD-883, and as specified herein.
 - 2.2 Test plan.
- 2.2.1 <u>Test flow</u>. A test plan detailing all materials, manufacturing construction techinques, and testing and reporting requirements shall be submitted to the qualifying activity with application for a NIL-STD-1772, section A, certification audit and shall be approved prior to implementation. This test plan shall include test travelers meeting the requirements for travelers in NIL-N-38534, appendix A. The revision level of all documents shall be included.

- 2.2.2 <u>Testing location</u>. Diagrams shall be supplied with the test plan detailing and labeling the location on the individual sample of the actual testing (i.e., die placement, wire bonding, resistor location, etc.).
- 2.2.3 Test limits. All test limits shall be in accordance with MIL-H-38534, MIL-STD-883, and the requirements specified herein. Delta limits for selected electrical parameters such as VCE (\$AT) and VF or other electrical tests shall be specified and in accordance with applicable or most similar military detail specification.
- 2.3 Test data. Test data shall be submitted to the qualifying activity. This data shall include a summary of attributes results for all required tests and measurements including preconditioning. A traveler containing all the specified details of Mil-M-38534, appendix A, is sufficient to meet this requirement. Variables data shall also be provided for the following tests:
 - a. Bond strength testing. The forces at the time of failure and the failure category or the minimum and maximum readings for the devices if no failure occurs.
 - b. Die shear strength testing. The force at the time of failure and failure category or the die shear force if no separation occurs.
 - c. Conductivity/resistivity testing. The "ohm per square" readings shall be recorded.
 - d. Internal water-vapor testing. Actual water-vapor content readings shall be provided.
 - e. VCE (SAT), VF or other electrical testing. Ressured parameter values shall be recorded and submitted.
 - f. Febricated resistors. Design, printed, and trimmed values shall be recorded and submitted.
 - g. Other data as required by the qualifying activity.
- 2.3.1 <u>Submitted data</u>. Original travelers and data sheets shall be submitted; or travelers and data sheets which have been varified by the Government source inspector as being copied from the original. Altered records shall not be considered acceptable unless the requirement of MIL-H-38534 for changes or transfers of records are met.

2.4 Test samples.

- 2.4.1 <u>Semple construction</u>. The test samples shall be fabricated, assembled and tested in a facility certified to MIL-N-38534 and MIL-STD-1772 using representative materials, manufacturing construction techniques and approved testing procedures in a actual production environment by trained personnel who perfors these operations on production devices. Appropriate production and test travelers shall be submitted to demonstrate compliance to this requirement. Materials and manufacturing construction techniques used in the fabrication and assembly of test samples shall be clearly documented, as this information will be required for subsequent qualification listings.
- 2.4.2 <u>Tracesbility</u>. All samples shell be serialized and identified as qualification samples before testing begins. This step shall be contained on all qualification test travelers. The test travelers shall indicate all, and only, certified steps and processes needed to conduct and control testing (i.e., serialization).

MIL-STD-1772B

- 2.4.3 Sample size. The sample size shall be as specified in the individual subsection. Sample sizes may be exceeded at the manufacturer's own risk.
- 2.4.4 <u>Sample submission</u>. All test samples shall be submitted to the qualifying activity with the testing results.
 - 2.5 <u>Pocumentation</u>.
- 2.5.1 <u>Materials and menufacturing construction technique documentation</u>. Materials and manufacturing construction technique documentation shall relate to the following. (This is a minimal requirement, complex situations may require additional documentation.)
 - Acquisition of semiconductor and other active devices, passive devices, substrates, packages, wire and related processing materials such as gases, chemicals, metals, polymers, etc.
 - b. Incoming inspection and methodologies.
 - c. Storage and handling, requirements and conditions.
 - d. Crizical parameter/procedure, process, and cleanliness control:
 - e. Environmental requirements and control.
- 2.5.2 <u>Test documentation</u>. Test plan documentation shall be submitted to the qualifying activity and shall list all required tests. Detailed limits and conditions for each required test shall be clearly specified in the documentation.
- 2.6 <u>Faitures</u>. All failed tests, resulting failure analysis, and corrective actions shall be submitted to the qualifying activity. This section is intended to provide the manufacturer with a vehicle to demonstrate capability to make hybrid micorocircuits using specific materials and manufacturing construction techniques. Therefore, if any particular testing results are not successful, the manufacturer shall perform failure analysis, take necessary corrective action, and adjust the process until all tests can be successfully performed. The manufacturer must notify the qualifying activity of any decision not to pursue qualification of any material or manufacturing construction technique previously approved by the authorization to test letter. Detailed supporting documentation must be tept and submitted to the qualifying activity when qualifying to section 8 of MIL-STD-1772.
- 2.6.1 Operator and equipment failure. The procedure in MIL-M-38534 for verifying operator and equipment failure shall apply.
- 2.7 <u>Polymeric materials</u>. All polymeric materials used in this testing shall be approved by the acquiring activity.
- 2.8 <u>Test deviation</u>. Additional or reduced testing, as may be dictated by the uniqueness of particular material and manufacturing construction techniques can be required or authorized by the qualifying activity. Alternate test plans must be specifically authorized by the qualifying activity.

, iÏ

MIL-STD-1772B

SUBSECTION 8-1

THICK AND THIN FILM FABRICATION

- 1. SCOPE
- 1.1 <u>Purpose</u>. This subsection provides for the evaluation of thick and thin film fabrication materials and techniques to assure that satisfactory electrical and mechanical performance will be obtained.
 - 1.2 Areas of concern. Areas of concern include the following:
 - 1.2.1 Substrate material.
 - a. Visual.
 - b. Mechanical.
 - 1.2.2 Metallization.
 - a. Corresion/exidetian.
 - b. Adhesion.
 - Solderability/leach resistance.
 - d. Bondability (wire).
 - e. Weldability.
 - f. Materials compatibility.
 - g. Age control/storage.
 - h. Thickness (wet/dry/fired).
 - i. Porosity/cracks.
 - j. Conductivity/resistivity.
 - 1.2.3 Insulating layers/passivation.
 - s. Adhesion.
 - b. Materials compatibility.
 - c. Age control/storage.
 - d. Thickness (wet/dry/fired).
 - e. Porosity/cracks/voids.
 - f. Dielectric strength.
 - 1.2.4 Resistors.
 - s. Stability (time, temperature, and voltage).
 - b. Materials compatibility.
 - Age control/storage.
 - d. Thickness (wet/dry/fired).
 - e. Cracks.

- f. Trim method compatibility
- g. Back lit porosity.

1.2.5 Overglaze/glassivation.

- e. Materials compatibility
- b. Age control/storage
- c. Thickness (wet/dry/fired)
- d. Porosity/cracks/voids/bubbles
- e. Trim method compatibility

1.2.6 Rework.

- 2. DETAILED REQUIREMENTS (See section 8 for general requirements)
- 2.1 <u>Test sample fabrication</u>. For each substrate material/fabrication technique combination to be qualified, 15 substrate assemblies shall be fabricated. The maximum number of layers for each substrate material/fabrication technique shall be demonstrated using appropriate workmanship standards.
 - 2.2 Test flow. The test flow shall be in accordance with table 8-1.
 - 2.2.1 <u>Test sample preconditioning</u>. The substrates shall be preconditioned before component assembly as follows:
 - a. Stabilization bake, method 1008, test condition C, 150°C for 24 hours.
 - b. Temperature cycling, method 1010, test condition C, 15 cycles.
 - 2.2.2 Test sample evaluation.
 - 2.2.2.1 <u>Conductivity/resistivity</u>. This test to be performed prior to semiconductor die attach test and wire bond adhesion test. films shall not exceed the maximum ohms per square limit that was referenced in the approved test plan after processing as determined by means of a four-point probe.
 - 2.2.2.2 <u>Film adhesion</u>. A minimum of three substrates from subgroup 1 shall be subjected to an adhesive tape test for film adhesion. The substrates shall show no evidence of film peeling or flaking.
 - 2.2.2.3 Die attach and wire bonding. A minimum of 12 samples that have been subjected to, and passed, subgroup 1 testing shall be submitted to subgroup 3.
 - 2.2.2.4 Internal vigual. Each sample shall be inspected in accordance with method 2017 of NIL-STD-883.
 - 2.2.2.5 <u>Vire bonds</u>. Each wire bond shall be tested in accordance with method 2011 of #IL-STD-883.
 - 2.2.2.6 <u>Die attach</u>. Each die attach shall be tested in accordance with method 2019 of MIL-STD-883.
 - 2.2.2.7 <u>Printed resistor</u>. As applicable, control of resistor fabrication and trimming shall be demonstrated by comparing design values to fired and trimmed values.

TABLE 8-1. Substrate fabrication qualification.

Subgroup	Test	MIL-STD-863		Quentity	Reference
		Hethou	Condition	(accept no.)	paragraph
Precondi- tioning	stabilization bake Temperature cycling	1008	C (24 hours, 150°C) C, 15 cycles	15 (0)	2.2.1a 2.2.1b
1	Conductivity/ resistivity test			15 (0)	2.2.2.1
	Printed resistor				2.2.2.7
2	Film adhesion test			3 (0)	2.2.2.2
3 .	Die attach and wire bonding			12 (0)	2.2.2.3
	Internal visual	2017			2.2.2.4
	Wire bonds	2011		,	2.2.2.5
	Die shear	2019			2.2.2.6

M1L-STD-17728

SURSECTION B-2

SURSTRATE AND ELEMENT ATTACHMENT

1. SCOPE

- 1.1 <u>Purpose</u>. This procedure provides for the evaluation of die and substrate attach to essure that satisfactory mechanical strength, heat transfer, and electrical performance will be obtained.
 - 1.2 Areas of concern. Areas of concern include the following.
 - 1.2.1 Mechanical and material characteristics.
 - Strength of the element and substrate attach initially and throughout the life in accordance with method 5008;
 - b. Loose particles generated with the particular materials or method of attachment.
 - c. Naterials outgassing causing surface problems with subsequent process steps.

1.2.2 <u>Thermal characteristics</u>.

- a. Thermal coefficients of expansion of constituent materials.
- b. Heat transfer characteristics of substrate and die attachment materials.

1.2.3 Electrical characteristics.

- Interelement contact resistance initially and throughout the life of the hybrid.
- b. Electrical surface leakage currents due to outgassing contamination or moisture content of the package.
- c. Optimization of microwave hybrid device characteristics that use the substrate as a ground plane by selection of attachment materials.
- 2. DETAILED REQUIREMENTS (See section & for general requirements.)
- 2.1 <u>Test sample construction</u>. A minimum of 12 identical test sample hybrid devices shall be constructed for each type of substrate and element ettach to be qualified. They shall be representative of the substrate and element attach systems (methods and materials) used in regular production. A minimum of two elements of each configuration to be qualified shall be attached per sample.
- 2.2 Test flow. Test flow shell be in accordance with table 8-2. Twelve samples shall be subjected to preconditioning. Six samples from preconditioning shall be subjected to each subgroups 1 and 2. Three samples (2 reworks, 1 nonrework) from each of subgroups 1 and 2 shall be subjected to subgroup 3. Three samples (2 reworks, 1 nonrework) from each of subgroups 1 and 2 shall be subjected to subgroup 4. Substrate and element attach may be tested separately. If these are tested separately, substrate attach testing need not include the tests or elements for VCE (SAT) or Vf, and die shear testing. Element attach testing shall always include all the tests of table 8-2.
- 2.2.1 Test sample preconditioning. Test samples shall be preconditioned using the operations identified in table B-2, and shall include element and substrate rework to be qualified.

- 2.2.1.1 Rework. Qualification of rework permitted in MIL-M-38534 shell be accomplished by replacing elements and the substrate. If rework is to be qualified, all but four samples shell be reworked. Two elements per each reworked sample shall not be reworked. These nonreworked elements and samples shall be clearly identified in order to provide rework versus nonreworked data. The rework cycle starting with the first step in preconditioning shall be performed two times for polymer attached elements and one time for metallic attached elements. If this type of rework will not be performed in production, this sequence will not be applicable, and no rework will be qualified.
- 2.2.2 Test sample evaluation. Test samples shall be evaluated in accordance with the applicable test flow.
- 2.2.2.1 <u>Electrical tests</u>. Twelve samples (six from each subgroup 1 and 2) shall be subjected to VCE (SAT) or Vf. Each test sample shall measure VCE (SAT) using method 3071 (translator) of RIL-STD-750, or VF shall be VCE (SAT) measured using method 4011 (diode) of RIL-STD-750. This test is used to evaluate the attach interface.
- 2.2.2.2 Loose particles. The parts shall show no evidence of loose particles as a result of the element and substrate attachment processes. Any parts evidencing loose particles (PIND test rejects) shall be investigated after completion of the internal water vapor test. This shall be accomplished by fastening a piace of transparent tape over a 0.025 to 0.040 inch hole (the hole made during the water vapor test may be used). The part is then placed on the loose particle tester to capture the particles on the tape. The captured particles shall be examined at 30% minimum and evaluated. The cause of the loose particles shall be determined and corrected.
 - 2.2.2.3 Radiography. For metallic attachment only. The parts shall show evidence of good wetting, with no part having less than 50 percent coverage. For subgroup 2, radiography may be done in process to enhance x-ray.

2.2.2.4 Internal water vapor.

- 2.2.2.4.1 <u>Subgroup 1</u>. Three samples with zero reject or five samples with one reject shall have a maximum internal water vapor content of 5000 perts per million. Other gas species presenting quantities greater than 1000 parts per million (0.01 percent) shall be reported.
- 2.2.2.4.2 <u>Subgroup 2</u>. Internal water vapor content testing is for information only. All constituents shall be reported.
- 2.2.2.5 <u>Internal visual</u>. Particular stention shall be focused on the quality of stachment material. Crazing, cracking, peeling, and recrystallization (for metallic attachment) shall not be present. Only rejects resulting from the attachment procedure shall be considered for this evaluation.
- 2.2.2.6 Constant acceleration. The parts shall withstand a minimum of 15 kg. If a part would be stressed to a higher constant acceleration level in MIL-STD-883, test method 5008 acreening, then the part shall be tested as a minimum to this higher level. A stiffener plate (e.g., .125 inch sluminum) may be attached to the base-plate of the package to prevent damage due to "oilcanning" of the package.
- 2.2.2.7 <u>Internet visual and mechanical</u>. In addition to the criteria of MIL-STD-883, method 2014, this inspection shall verify that no damage has occurred to element and substrate attach.

TABLE 8-2. Substrate and element attach qualification.

Subgroup	Test	H1L-STD-883		Quantity	Reference
		Method	Conditions	(accept no.)	paragraph (see 2.2)
Precondi- tioning	Internal visual Stabilization bake Temperature	2017 1008 1010	c(100 hours at 150°C)	12 (0)	2.2.2.5
	cycling	2001	A, Y, axis	1	2.2.2.6
	acceleration	2017	only	}	2.2.2.5
	Rework Seal External visual	1014 2009		:	2.2.1.1
	VEE (SAT)ot	3071		. 6 (0)	2.2.2.1
· · ·	VF Temperature cycling	4011 1010	c (100 cycles)		
	Constant; acceleration PIND test	2001	A, Y axis	:	2.2.2.6 2.2.2.2 2.2.2.1
	VCE (SAT)or VF Radiography Internal water-	3071 4011 2012 1018		3(0) or 5(1)	2.2.2.3
vapor Loose p					2.2.2.2
2	VCE (SAT)or VF	3071 4011 1008	C (1000 hours	6 (0)	2.2.2.1
bake Constan accel PIED te VCE (SA Vf Rediogr Interna vapor	bake Constant	2001	et 150°C) A, Y, exis		2.2.2.6
	pied test VCE (SAT)or	2020 3071	B		2.2.2.2
	tediography Internal water-	4011 2012 1018	ļi.	3(0) or 5(1)	2.2.2.3
	vapor Loose particle recovery	ŀ			2.2.2.2
3	Hechanical	2002	c	6 (0)	
	shock VCE (SAT)or VF	3071			2.2.2.1
	Internal visual Die shear	2017	·		2.2.2.5
4	Constant ecceleration	2001	C (minimum)	6 (0)	2.2.2.6
	External visual Internal visual and mechanical	2009 2017			2.2.2.7

HIL-STD-17728

SUBSECTION B-3

BONDING, INTERNAL

- 1. SCOPE
- 1.1 <u>Purpose</u>. This subsection provides for the evaluation of hybrid microcircuit internal bonding techniques to assure that the manufacturing construction technique being evaluated will result in satisfactory mechanical strength and electrical performance.
 - 1.2 Areas of concern. Areas of concern include the following.
 - 1.2.1 Mechanical characteristics.
 - s. Strength of the wire/bond attachment initially and throughout life in accordance with method 5008 of NIL-STD-883.
 - b. Bonding schedules considering the following in the development of the schedules.
 - (1) Element technology.
 - (2) Package technology.
 - (3) Thick and thin file substrate technology.
 - (4) Attachment materials.
 - (5) Heat spreaders.
 - (6) Bonding pad size.
 - (7) Bonding surface characteristics.
 - (8) Aluminum wire, verious sizes used.
 - (9) Gold wire, various sizes used.
 - (10) Bonding machine technique, (wedge-wedge, gold ball, thermosonic, ultrasonic, thermocompression, etc.).
 - 1.2.2 Chemical characteristics. Hybrid microcircuit bonding surface cleanliness.
 - Z. DETAILED REQUIRMENTS
- 2.1 <u>Test sample construction</u>. A minimum of four hybrid device test samples with a minimum of 120 bond wires (30 wires per sample) shall be fabricated for this evaluation. Evaluation of wire bonding to table 8-3 shall be performed for each combination of the following materials and techniques to be qualified.
 - s. Bonding technique.
 - b. Manual bonding.
 - c. Automatic bonding.
 - d. Wire composition.
 - e. Smallest wire/ribbon dismeter.
 - f. Largest wire/ribbon dismeter.
 - g. Conductor material.

WIL-STD-17728

2.1.1 <u>lest sample content</u>. Each test sample device shall contain elements typical of device assembly and shall include, as a minimum, an integrated circuit, transistor, diode, capacitor and resistor chip. Thick and thin film capacitor and resistor chips shall be used. Wire bonds shall include one wire from each type of transistor, diode, capacitor and resistor chip, three wires from each type of integrated circuit and five wires connecting package leads per sample, as applicable.

NOTE: Only those chips actually used in the manufacture of hybrids are required. For example, if thin film resistor chips are not used in manufactured devices, this type of chip would not have to be included in the sample devices.

- 2.2 Test flow. Tests and test flow shall be as specified in table 8-3. Two units each shall be subjected to subgroups 1 and 2 testing. Only sealed devices shall be subjected to subgroup 1.
- 2.2.1 <u>Vire bonds</u>. Wire bonds shall have a minimum post-bake strength of at least half the value specified for bonds evaluated at post sealing in accordance with method 2011 of MIL-STD-883.
- 2.2.2 Simulated rework. Simulated rework shall consist of a one-hour bake at 165°C minimum or actual rework.
 - 2.2.3 Mire bond rework. All Mire bonds for subgroup 2 shall be replaced. If no wire bond rework is to be qualified, all units shall be subjected to subgroup 1 testing.
 - 2.2.4 <u>Constant acceleration</u>. As an alternate, mechanical shock (method 2002) may be used. The level of stress to be applied shall be that used in screening as a minimum.

MIL-610-17728

TABLE 8-3. Bonding. internal qualification.

Subgroup	Test	Method	STD-883	Quantity (accept no.)	Reference peragraph
Precandi.	Internal visual	2017		4 (0)	
tioning	Simulated rework	2017			2.2.2
	Mondestructive bond pull	2023			,
	Internal visual Package seal	2017			
	Stablization bake	1008	c (24 hours		
	Temperature cycling	1010	C	-	
	Mechanical shock Seal	2001	B (Y, only)		
	Jemperature cycling	1010	Cycles)	• • •	
1	Stablization bake	1008	F (1 hour)	2 (0)	
	Package delid	2017			}
	bestructive bond pull	2011			2.2.1
2	Delid Wire bond			2 (0)	2.2.3
	rework Internal visual	2017		·	
	Package reseal	1014			
	Stablization bake	1008	F (1 hour)		
	Package delid Internel visual Wire bonds	2017 2011			2.2.1

SUBSECTION 8-4

SEALING, DELIDDING, AND RELIDDING

1. SCOPE

- 1.1 <u>Purpose</u>. This subsection provides for the evaluation of techniques for sealing, delidding, and relidding hybrid microcircuit packages to assure hermeticity and to assure that loose particles are not introduced into the hybrid microcircuit as a result of these operations.
 - 1.2 Areas of concern. Areas of concern include the following:

1.2.1 Processes.

- a. Precap cleaning procedure, lid and cover cleaning operations, and sealing (dry) box cleanliness control methods.
- b. Sealing environment: Moisture continually monitored, temperature, moisture and \$2 atmosphere specified, plus tracer gas, if used, and method of control identified.

1.2.2 Mechanical.

- Ability to meet seal integrity and external visual in accordance with methods 1014 and 2009 of NIL-STD-883.
- b. Control of temperature, time, and other parameters that affect the sealing process.
- c. Control of loose particles generated by the initial seal, seal rework, defidding, and relidding techniques.
- d. Records of weld or eutectic schedules and seal parameters for each size package used, for each package supplier.
- 1.2.3 <u>Electrical</u>. Ability to prevent pin-to-case or pin-to-pin shorts from solder, loose particles or other conductive material.
- 1.2.4 <u>Internal water vapor content</u>. Ability to monitor moisture within the sealing chamber and to evaluate the moisture and gas content of the sealed package in accordance with method 1018 of NIL-STD-883.
 - 2. DETAILED REQUIREMENTS (See section 8 for general requirements.)
- 2.1 <u>Test sample construction</u>. A minimum of 22 electrically functional hybrid device test samples shall be fabricated for this evaluation. Additional groups of similar test samples shall be fabricated for each different package type and sesting technique used. The test samples shall be representative of devices in or to be in regular production, in the largest 11 and smallest 11 package sizes. If the smallest and largest seal perimeter packages are not available for testing, consideration shall be given by the qualifying activity for the use of the next available perimeter size.
 - 2.2 Test flow. Tests and test flow shall be as specified in table 8-4.
- 2.2.1 <u>Seal rework</u>. Rework of fine leak rejects shall be permitted only if requirements of NIL-H-38534 are met, and have been approved during the section A audit.
- 2.2.2 <u>Electrical testing</u>. Electrical testing shall, as a minimum, include all 25°C group A subgroups required for final electrical in acreening and group A testing in quality conformance evaluation.
 - 2.2.3 Rediography. For solder seal only.

2.2.4 PIND and toose particle detection. The parts shall show no evidence of toose particles resulting from the seal, delid or reseal process. Any parts showing toose particles shall be investigated. The investigation shall consist of fastening a piece of transparent tape over a small hole (.025 to .040 inch) punched in the lid. The part is then placed on the loose particle tester to capture the particles on the tape. The captured particles shall be examined at 30% minimum. The cause of the loose particles shall be determined and corrected.

NOTE: Loose particle recovery is only required for PIND rejects.

NOTE: Since very small metallic particles could be generated during the process of delidding and preparing the sealing surface for resealing, a careful inspection is required to detect latent defects, particles which could, in time, find their way across the glass beads. Any evidence, either visual or electrical, of these particles shall require corrective action.

- 2.2.5 <u>Internal water vapor</u>. Three samples (0 failures) or 5 samples (1 failure) shall have a minimum internal water vapor content of 5000 ppm for class. B or 3000 ppm for class S. If possible, PIND rejects shall not be used for internal water vapor teating.
- 2.2.6 <u>Delidding and relidding evaluation</u>. This sequence shall be performed only for those packages for which the one delid is to be qualified. If delid is not to be qualified, then subgroup 2 is not applicable.
- 2.2.6.1 <u>Delidding and relidding procedure</u>. After completion of all tests and if delidding is to be qualified, the parts shall then be delidded one time and the sealing surface prepared for relidding using documented procedures. In order to assure that no loose conductive particles are still in the package, the following tests shall be performed:
 - a. Internal visual inspection: Nethod 2017 of MIL-STD-883.
 - b. Utilization of appropriate cleaning methods to achieve the required level of cleanliness.
 - c. The parts shall be visually examined for loose particles which have been introduced during the delidding operation. Burrs on seal areas must be removed. Preseal visual inspection in accordance with method 2017 of MIL-STD-883.
 - d. The parts shall be resealed using documented procedures.
 - e. Subgroup 1 is repeated.

MIL-STD-17728

TABLE 9-4. Sealing, delidding, and relidding qualification.

Subgroup	Test	MIL-STD-883		Quantity	Reference
	}	Method	Conditions	(eccept no.)	paregraph
1	Seal	1014		22 (0)	
	Seel rework				2.2.1
	External visual	2009			ļ
	Electrical		25°C only		2.2.2
Ì	Radiography	2012			2.2.3
	Temperature	1010	C, (50		
	cycling	1	cycles)	1	
	Vibration,	2007	8		į .
ĺ	variable		Ì	Ì	İ
·	frequency		1	1	i
	Seat	1014			l <u></u> .
	PIND test	2020	B	· .	2.2.4
	Electrical		25°C only		
r e	internal mater-	1018		3 (D) or	2.2.5
	vapor content			5 (1)	2.2.4
	Loose particle '				
2	petid			22 (0)	2.2.6
-	1	l]: `-'	2.2.6.1

W11-STD-1772B

SUBSECTION 8-5

QUALIFICATION OPTION

1. SCOPE

- 1.1 <u>Purpose</u>. This subsection establishes the requirements particular to qualification option. Materials and manufacturing construction techniques listed on the QML shall be for those materials and manufacturing construction techniques which are actually tested.
- 1.2 Areas of concern. Areas of concern include all those listed in subsections 8-1, 8-2, 8-3, and 8-4.
 - 2. DETAILED REQUIREMENTS (See section B for general requirements.)
 - 2.1 <u>lest vehicle</u>.
- 2.1.1 Test sample construction. A list of materials and manufacturing construction techniques to be qualified by the manufacturer shall be submitted to the qualifying activity. A test vehicle shall be defined based on the manufacturer's assessment of the most critical fabrication, assembly, and material technologies; and can be actual production devices or devices specifically designed for this purpose.
- 2.1.2 <u>Preconditioning</u>. The test vehicle shall be fully acreened to method 5008 of Mil-STD-883 before qualification testing is commenced. Additionally, all rework to be qualified shall be demonstrated as part of preconditioning. Two test devices and two elements per each reworked test device shall not be reworked. These nonreworked elements and test vehicles shall be clearly identified in order to provide reworked versus nonreworked data. Evidence of these preconditioning steps shall be presented to the qualifying activity as part of the test traveler.
- 2.1.3 <u>Inspection of package</u>. The devices shall be checked for evidence of damage. Special fixturing may be used to prevent damage to the package if the force used in the test is greater than that which would be used in normal MIL-STD-883, test method 5008, testing.
- 2.1.4 <u>Wire bond testing</u>. The bond strength test shell be performed to a lot tolerance percent defective (LTPD) of 7 for the number of bonds. The sample wires shall be predesignated, representative of the bonds to the various elements, and evenly distributed among the sample parts.
- 2.2 Tests and test flow. For initial qualification, the test and test flow as a minimum, shall be in accordance with table 8-5A. For qualification of new or additional processes or materials, the tests and test flow, as a minimum, shall meet the requirements of table 8-58.
 - 2.2.1 Electrical testing. Electrical testing shall be at 25°C only.
- 2.2.2 <u>Honfunctional amples</u>. Electrical rejects from final electrical testing in screening can be used for subgroups 4, 5, and 6 testing. Only sealed units shall be subjected to subgroup 4.
- 2.2.3 <u>Sampling</u>. The same sample parts may be used for subgroups 1, 2, and 3 testing; and those tests identified in NIL-E-38534 as destructive can be performed only in subgroup 3.
- 2.3 Test limits. All test limits, as a minimum, except as noted herein, shall meet the requirements noted in MIL-M-38534 and MIL-STD-883.

2.3.1 <u>PIND and loose particle detection</u>. The parts shall show no evidence of loose particles. Any parts showing loose particles shall be investigated. The investigation shall consist of fastening a piece of transparent tape over a small hole (.025 to .040 inch) punched in the lid. The part is then placed on the loose particle tester to capture the particles on the tape. The captured particles shall be evaluated at 30% minimum and the offending portion of the process identified and corrected.

MOTE: Loose particle recovery is only required for PIMD rejects.

- 2.3.2 <u>Internal visual and mechanical</u>. Loose particle recovery and internal water vapor testing shall be performed carefully to minimize damage to the areas to be inspected.
 - 2.3.3 Internal water vepor.
- 2.3.3.1 <u>Subgroup 3.</u> Internal water vapor content testing is for information only. All constituents shall be reported.
- 2.3.3.2. <u>Subgroup 6.</u> Three samples (0 failures) or five samples (1 failure) shall have a maximum internal water vapor content of \$000 parts per million. Other dus species present in quantities greater than 100 parts per million (0.01 percent) shall be reported.
- 2.3.4 Constant acceleration. The parts shall withstand a minimum of 15 kg. If a part would be stressed to a higher constant acceleration level in MIL-STD-883, test method 5008 screening, then the part shall be tested as a minimum to this higher level. A stiffener plate (e.g., .125 inch aluminum) may be attached to the base-plate of the package to prevent damage due to "ollcanning" of the package.
- 2.3.5 <u>Die sheer</u>. Die sheer shelt be performed on all elements in five devices with zero failures allowed.
- 2.3.6 <u>internal visual and mechanical</u>. In addition to the criteria of MIL-SID-883, method 2014, this inspection shall verify that no damage has occurred to the element and substrate attach.

MIL-STD-17728

, TABLE 8-5A. Qualification subgroups.

Subgroup	Test	Dodsen	Conditions	Quantity (accept no.)	Reference paragraph
1	Thermal shock Temperature cycling Constant acceleration or Mechanical shock	1011 1010 2001 2002	C, 15 cycles C, 100 cycles A, Y, exis only B, Y, exis	5 (0)	2.3.4
	Seal PIND Electrical Loose particle recovery Internal visual and mechanical	1014 2020 2014	25°C only		2.3.1 2.2.1 2.3.1, 2.3.2
· · · · · ·	Die isteer	2019	·	· · · · _	2.3.5
2	Mechanical shock Variable frequency vibration Constant acceleration External visual	2009	E, Ty only Tonly A, Ty only	5 (0)	2.3.4
	Seal PIND :Electrical Loose particle recovery Internal visual	1014 2020	B 25°C only		2.3.1 2.2.1 2.3.1, 2.3.2
	and mechanical	2014			2.2.3, 2.3.2
3	Stabilization bake Constant acceleration Seal Electrical Internal water vapor Internal visual and wechanical	1008 2001 1014 1018	150°C, 1000 hours Y ₁ only 25°C only	\$ {0}	2.3.4 2.2.1 2.3.2, 2.3.3.1
	-		<u> </u>		2.3.0
•	Stabilization bake Bond strength	1008 2011	f, i hour	5 (0)	2.1.4
5	Constant acceleration Internal visual and mechanical	2001 2014	C minimum (7, mxis only)	5 (0)	2.3.4 2.3.6
6	Internal water wapor	1018		3 (0) or 5 (1)	2.3.3.2

#11-STD-17728

TABLE 8-58. Testing guidelines for process and material changes or additions.

	Qualification test subgruops (from table 8-5A)
Substrate material	1, 2, 3, 4, 5
Conductor meterial or process temperature	1, 2, 3, 4, 5
Die or element attach materials	1, 2, 3, 4, 5, 6
Substrate attach material or process temperature	1, 2, 3, 4, 5, 6
Package/tid structure or plating material	1, 2, 3, 4, 5
Peckage lid/base material	1, 2, 3, 5
Wire bond method, materials or dimensions	1, 4
Soal method, process, material or etmosphere	1, 2, 3, 6

CONCLUDING MATERIAL

Custodians: Army - ER Mavy - EC Air Force - 17 MASA - MA

Review activities:
Army - Ak, N1
Navy - SN
Air Force - 11, 19, 85, 99
OLA - ES

User activities: Army SM Navy AS, CG, NC, OS Preparing activity: Air Force - 17

Agent: DLA - ES

(Project 5962-1222)